

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

July 4, 2025

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

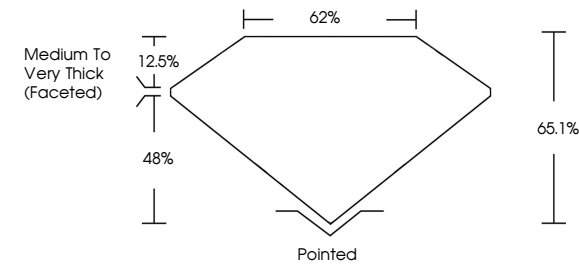
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

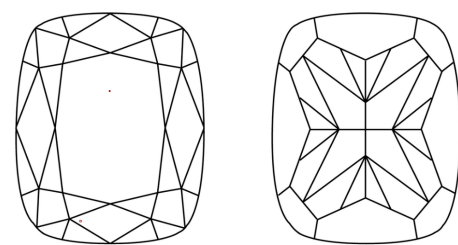
LG719511102

Report verification at igi.org

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.


COLOR

D E F G H I J Faint Very Light Light


CLARITY

IF VS 1-2 VS 1-2 SI 1-2 I 1-3 Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

Sample Image Used



LABORATORY GROWN DIAMOND REPORT



July 4, 2025

IGI Report Number

Description

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

LG719511102

LABORATORY GROWN DIAMOND

CUSHION MODIFIED BRILLIANT

8.60 X 6.64 X 4.32 MM

2.01 CARATS

D

VS 1

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)


Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

EXCELLENT

EXCELLENT

NONE

IGI LG719511102



IGI

July 4, 2025

IGI Report No LG719511102

CUSHION MODIFIED BRILLIANT

8.60 X 6.64 X 4.32 MM

2.01 CARATS

D

VS 1

65.1%

62%

Medium to Very Thick (Faceted)

Pointed

EXCELLENT

EXCELLENT

NONE

IGI LG719511102

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

© IGI 2020, International Gemological Institute

FD - 10 20

www.igi.org

THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES.